

Form PTO 1449 (Modified)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY DOCKET NO. 293482US0PCT		SERIAL NO. 10/588,080	
LIST OF REFERENCES CITED BY APPLICANT				APPLICANT Naoyoshi HATAKEYAMA, et al.			
				FILING DATE January 10, 2007		GROUP 1752	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
	AL						
	AM						
	AN						
FOREIGN PATENT DOCUMENTS							
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					YES	NO	
	AO	WO 03/104182 A1	12/18/2003	WIPO			
	AP	EP 0 999 474 A1	5/10/2000	Europe			
	AQ	EP 1 577 285 A1	9/21/2005	Europe			
	AR	EP 1 803 708 A1	7/4/2007	Europe			
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	AW	K. E. GONSALVES, et al., "High performance resist for EUV lithography", DATABASE CA [ONLINE], CHEMICAL ABSTRACTS SERVICE, XP-002461455, accession no. 2004: 1001937, Microelectronic engineering, 2005, 1 Page					
	AX						
	AY						
	AZ					<input type="checkbox"/> Additional References sheet(s) attached	
Examiner				Date Considered			